

CHAPTER V

CONCLUSION

The hydrogen desorption/absorption of $\text{HfCl}_4\text{-NaAlH}_4$ with the chelating compound (H_2TPP and HfCl_2TPP) as a co-catalyst were carried out over a temperature range of 25-280 °C. The hydrogen desorption took place at the temperature range of 170-220 °C, the pressure of 11 MPa, with 4.5 wt% and 3 wt% hydrogen released with the addition of H_2TPP and HfCl_2TPP into doped NaAlH_4 , respectively. The sequent addition of the chelating compounds affected the desorption kinetics and reversibility of hydrogen desorption on NaAlH_4 . With the simultaneous addition of the chelating compound with HfCl_4 and NaAlH_4 , hydrogen desorption was low. The more organic compound was added, the less hydrogen was released. However, when 4mol% HfCl_4 and NaAlH_4 were mixed before adding H_2TPP , hydrogen released was about 5.5 wt%. Moreover, adding H_2TPP significantly lowered the temperature of the first hydrogen desorption from 90 °C to 75 °C. The subsequent dehydrogenation cycles occurred at higher temperature (90-150 °C) and the amount of hydrogen released was about 0.7-1.0 wt%. The Hf-Al alloy formation could be prevented as intended by adding the chelating compounds. The HfH_x , where $0 < x < 2$, was found in the desorbed sample of $\text{HfCl}_4\text{-NaAlH}_4$ doped the chelating compound.

When using CuCrO_4 as another co-catalyst, the hydrogen desorption took place at the temperature range of 62-270 °C. The temperature of the first hydrogen desorption decreased much further to 62 °C and the hydrogen released was 5.9 wt%, which was higher than the theoretical value of 5.6 wt%. The equivalent mole of H_2 released per one equivalent mole of NaAlH_4 was increased to 1.65, compared to 1.5 of NaAlH_4 doped with HfCl_4 alone, as can be seen from the following equations.

